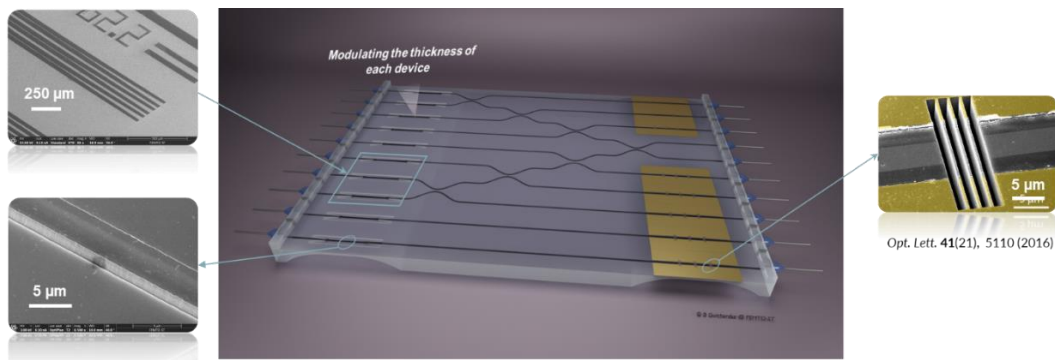


**High-Performance Broadband Nonlinear Photonic Platform Based on Thin-Film LiNbO<sub>3</sub>**  
Aiman Zinaoui <sup>1a\*</sup>, Lucas Grosjean<sup>a</sup>, Jean-David Fayssaud<sup>a</sup>, Arthur De Sousa Lopes Moreira<sup>a</sup>,  
Antoine Coste<sup>a</sup>, Miguel Angel Suarez<sup>a</sup>, Ludovic Gauthier-Manuel<sup>a</sup>, Samuel Queste<sup>a</sup>, Laurent  
Robert<sup>a</sup>, Mathieu Chauvet<sup>a</sup>, Nadège Courjal<sup>a</sup>

<sup>a</sup>Femto-St Institute, Université de Bourgogne-Franche-Comté, 25000 Besançon, France

Highly tunable LiNbO<sub>3</sub> (LN) frequency conversion platforms are gaining interest due to their potential in quantum computing, spectroscopy, neuromorphic networks, or aerospace technologies. Conventional nonlinear LN platforms, based on type 0 Quasi-Phase-Matching and combined with sub-micrometer LNOI waveguides, offer high conversion efficiencies (2500 %/W/cm<sup>2</sup>)<sup>1</sup>. However, they suffer from limited spectral tunability and short interaction lengths of a few millimeters. This also correlates with stringent waveguide dimension geometric tolerances such as sub-2 nm thickness precision for a 5 mm interaction length<sup>2</sup>. To address these challenges, we propose a new frequency-conversion platform based on a rib waveguide suspended in air and type I birefringent phase matching between fundamental modes. This approach extends the tunability bandwidth up to 900 nm and relaxes 5 times the manufacturing tolerance. The required LN film thickness must be around 2 μm, which is unfortunately beyond the thickness range of LNOI technology. To achieve this specific thickness, we developed a new manufacturing process at the MIMENTO technology center, with facilities provided by the Renatech network, based on precision saw thinning followed by a more precise Reactive Ion Etching (RIE) thinning sequence. We can then achieve a good thickness control in the range of 700 nm to 500 μm from a monolithic LN wafer. Moreover, the rib waveguide, inscribed via standard dry RIE process, is adiabatically coupled to titanium-diffused waveguides at both input and output, enabling low coupling loss (0.8 dB/facet) and single-mode operation. This platform paves the way for a new generation of compact, broadband, and energy-efficient thin-film technologies, suitable for integrated frequency converters.



*Figure 1: Multi-scale integrated nonlinear photonic platform based on lithium niobate for enhanced frequency conversion and broadband tunability.*

**Bibliography:**

- [1] C. Wang, C. Langrock, A. Marandi, M. Jankowski, M. Zhang, B. Desiatov, M. M. Fejer, and M. Loncar, "Ultrahigh-efficiency wavelength conversion in nanophotonic periodically poled lithium niobate waveguides," *Optica* 5, 1438 (2018).
- [2] P. S. Kuo, "Noncritical phasematching behavior in thin-film lithium niobate frequency converters," *Opt. Lett.* 47, 54 (2022).

\* Corresponding author: [aiman.zinaoui@femto-st.fr](mailto:aiman.zinaoui@femto-st.fr)